

Thick lead-free ferroelectric films with high Curie temperatures through nanocomposite-induced strain

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Ferroelectric materials are used in applications ranging from energy harvesting to high-power electronic transducers¹. However, industry-standard ferroelectric materials contain lead, which is toxic and environmentally unfriendly². The preferred alternative, BaTiO₃, is non-toxic and has excellent ferroelectric properties, but its Curie temperature of ~130 °C is too low to be practical³. Strain has been used to enhance the Curie temperature of BaTiO₃ (ref. 4) and SrTiO₃ (ref. 5) films, but only for thicknesses of tens of nanometres, which is not thick enough for many device applications. Here, we increase the Curie temperature of micrometre-thick films of BaTiO₃ to at least 330 °C, and the tetragonal-to-cubic structural transition temperature to beyond 800 °C, by interspersing stiff, self-assembled vertical columns of Sm₂O₃ throughout the film thickness. The columns, which are 10 nm in diameter, strain the BaTiO₃ matrix by 2.35%, forcing it to maintain its tetragonal structure and resulting in the highest BaTiO₃ transition temperatures so far.

Many ferroelectric systems are being studied as replacements for PbZr_xTi_(1-x)O₃, with bismuth layered compounds⁶ being a popular subject of investigation. Although the T_c for these materials can be high, up to 790 °C, property optimization is difficult due to the need for careful textural alignment. BiFeO₃ and other titanate perovskites are alternative high- T_c ferroelectrics; however, their processing windows are narrow, and doping needs to be extremely precise^{7–9}. Haeni *et al.*⁵ first demonstrated the enhancement of T_c in SrTiO₃ thin films by making use of substrate-induced epitaxial strain, with Choi *et al.* demonstrating the same in BaTiO₃ films⁴. However, because of strain relaxation through the thickness of these films, increasing T_c by means of substrate control is limited to films that are only tens of nanometres thick^{10,11}, which is impractical, because many ferroelectric devices require much thicker films.

A novel method to provide strain control in much thicker films involves the growth of vertical nanocomposites^{12–16}. In BiFeO₃:Sm₂O₃ (ref. 17), high compressive vertical strain levels of ~1.5% have been demonstrated, with a strong improvement in dielectric properties and reduced leakage¹⁸. Here, we demonstrate a nanocomposite system of BaTiO₃:Sm₂O₃ that generates out-of-plane tension in the BaTiO₃ (BTO) of ~2.35%. Sm₂O₃ (SmO) is the ideal strain controlling second phase because it substitutes only minimally into the BTO, it has a large elastic modulus

(125 GPa, compared to 67 GPa for BTO) and is insulating^{19,20}. In >1- μ m-thick films, a strong increase in the tetragonal to cubic phase transition temperature, from 130 °C to >800 °C, and concomitant increase in Curie temperature are demonstrated. Such enhancements in thick films have opened a new approach to using BTO in high-temperature ferroelectric applications.

Films were grown using pulsed laser deposition (from a single target containing a 50:50 mix of BTO and SmO) onto (001) Nb-doped SrTiO₃ substrates at 800 °C. Figure 1 presents cross-sectional transmission electron microscopy (TEM) images of 600-nm-thick composite films, showing self-assembled SmO nanocolumns with diameters of ~10 nm, which are evenly sized and distributed, embedded in a BTO matrix. The nanocolumns extend perpendicular to the substrate through the entire thickness of the film (Fig. 1a,c). The composite nanostructure arises from a process of nucleation and growth, with small, cylindrical pillars forming (Fig. 1b) to allow the surface energy of the BTO matrix to be minimized²¹. This nanostructure is similar to that of BaTiO₃:CoFe₂O₄ composites²², except that it is the lower compliance CoFe₂O₄ rods that adapts to accommodate the mismatch strain (–0.8% out-of-plane); here, critically, it is the BTO matrix that is the lower compliance phase and therefore becomes strained (+2.35% out-of-plane).

From X-ray scans, the in-plane orientation for BTO was found to be $\langle 100 \rangle_{\text{BTO}} \parallel \langle 100 \rangle_{\text{STO}}$ and for the SmO $\langle 100 \rangle_{\text{SmO}} \parallel \langle 110 \rangle_{\text{STO}}$. Table 1 presents the room-temperature lattice parameters. It is found that $2 \times (001)_{\text{BTO-strained-comp.}} (= 2 \times 4.078 \text{ \AA} = 8.16 \text{ \AA}) \approx 3 \times (004)_{\text{SmO-strained-comp.}} (= 3 \times 10.913/4 \text{ \AA} = 8.18 \text{ \AA})$. A schematic of the crystallographic matching of the two phases consistent with these calculations is represented in Fig. 1d. The cell volume for the strained BTO is 65.8 Å³, which is close to that of bulk BTO (64.4 Å³), indicating minimal chemical modification of the BTO by the SmO. This was further confirmed by energy-dispersive X-ray spectroscopy (EDX) on individual crystals of BTO that had been reacted with SmO at 1,200 °C for 2 days.

Reciprocal space maps about the $(\bar{1}\bar{1}3)$ STO substrate reveal a clear shift in the position of the $(\bar{1}\bar{1}3)$ BTO peak from the pure film to the composite film (Fig. 2a,b). The pure BTO film is fully relaxed, as expected for this thickness of film (1 μ m). The $(\bar{1}\bar{1}3)$ pure BTO peak is broad, indicating a spread of lattice parameters, as is expected for a film that has gradual relaxation with increasing

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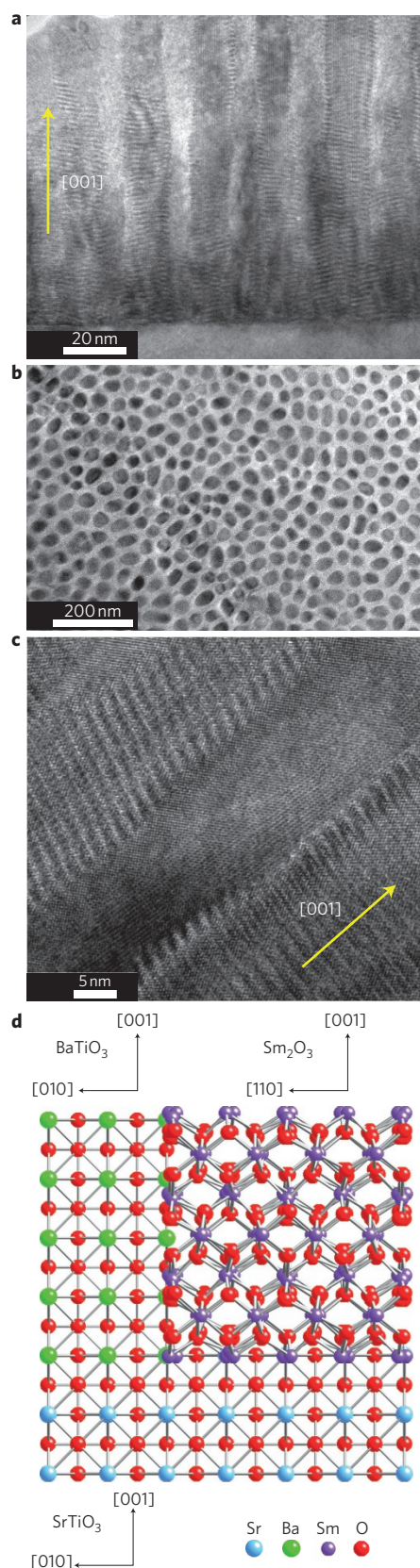


Figure 1 | Self-assembled vertical nanostructure. **a–c**, TEM images of a 600-nm-thick BaTiO₃:Sm₂O₃ film on SrTiO₃: cross-section (**a**) near the film-substrate interface; plan view (**b**); cross-section (**c**) revealing structure still present near the film-free surface. Sm₂O₃ shows a darker contrast compared with BaTiO₃. Yellow arrow represents *c*-axis direction. **d**, Crystallographic model of interface matching.

Table 1 | Lattice parameters of 1-μm-thick films.

	Out-of-plane lattice parameter (Å)	In-plane lattice parameter (Å)
SrTiO ₃ substrate (JCPDS # 35-0734)	3.9050	3.9050
BaTiO ₃ bulk ³³	4.0343(5)	3.9939(5)
Sm ₂ O ₃ bulk (JCPDS # 15-0813)	10.928*	10.928
Pure BaTiO ₃ film	3.984(3)	4.041(5)
Pure Sm ₂ O ₃ film	10.822(3)	11.014(5)
BaTiO ₃ in composite	4.078(3)	4.016(5)

* $a(\text{Sm}_2\text{O}_3)/4 \times \sqrt{2} \approx a(\text{STO})$.

thickness. The ($\bar{1}\bar{1}3$) BTO peak in the composite is shifted away from the ($\bar{1}\bar{1}3$) STO peak (Fig. 2b) and towards the ($\bar{4}08$) SmO peak, which shows both a lack of film relaxation and, more significantly, strain control by the SmO phase and not by the STO substrate. Also, the ($\bar{1}\bar{1}3$) BTO peak is much sharper than in the pure film, indicating little spread of the lattice parameters and hence little or no strain relaxation through the thickness of the film. For the BTO in the composite, the shift corresponds to an extension out-of-plane of +2.35% with respect to the pure BTO film (+1.07% with respect to bulk BTO) and a compression in-plane of -0.62% with respect to the pure BTO film. These levels of strain are sufficient from theoretical predictions to produce an increase in the transition temperature to the ~700–800 °C values measured here; the precise predicted value, however, depends on the particular model adopted^{4,23}. The stiffer SmO was only slightly compressed out-of-plane, as expected from its higher compliance compared to BTO.

Figure 2c shows the dependence of the *a* and *c* lattice parameters with temperature. For pure BTO bulk, the tetragonal to cubic phase transition is observed at 130 °C, as expected. For a 150-nm-thick composite film, the transition is in line with theoretical predictions for the level of strain in the film (~800 °C), whereas for a 600 nm film, at the highest possible measurement temperature of 800 °C, the transition has not yet taken place. The volume of the substrate-strained region is proportionally much less in the thicker film, allowing vertical strain to dominate the net behaviour and increase *T_c* by such a marked amount. A comparative 50 nm pure BTO film controlled by a highly mismatched substrate, with the highest previously reported transition of ~560 °C (ref. 4) is shown for reference. The 800 °C transition in this work is the highest transition temperature yet recorded in BTO; furthermore, this is achieved in micrometre-thick films.

Optical second harmonic generation (SHG) signals are plotted versus temperature for two composite samples in Fig. 2d. The dominant electric dipole contribution to optical SHG is exhibited only by materials that lack inversion symmetry. Because ferroelectrics lack inversion symmetry, the presence of SHG suggests a polar structure. There is no SHG signal in normal incidence for either sample, which is expected for out-of-plane polarization. However, for a finite angle of incidence at 45°, BTO produces an SHG signal. For the 1.25-μm-thick film, the transition temperature has increased to ~320 °C, below which long-range polar order sets in. Local polar order (without long-range correlation) continues up to ~700–800 °C, as indicated by a weak SHG signal and the inset polar plot. Analysis of the SHG polar plots suggests tetragonal symmetry with 4mm point group symmetry (equation 1), even at 795 °C (Fig. 2d, inset).

The thinner 600 nm film exhibits a diffuse transition in SHG, suggesting an inhomogeneous distribution of stress, consistent with some contribution of substrate strain control in material at the base of the film. Atomic displacement and field-switchable spontaneous polarization (that is, ferroelectricity) are two physically

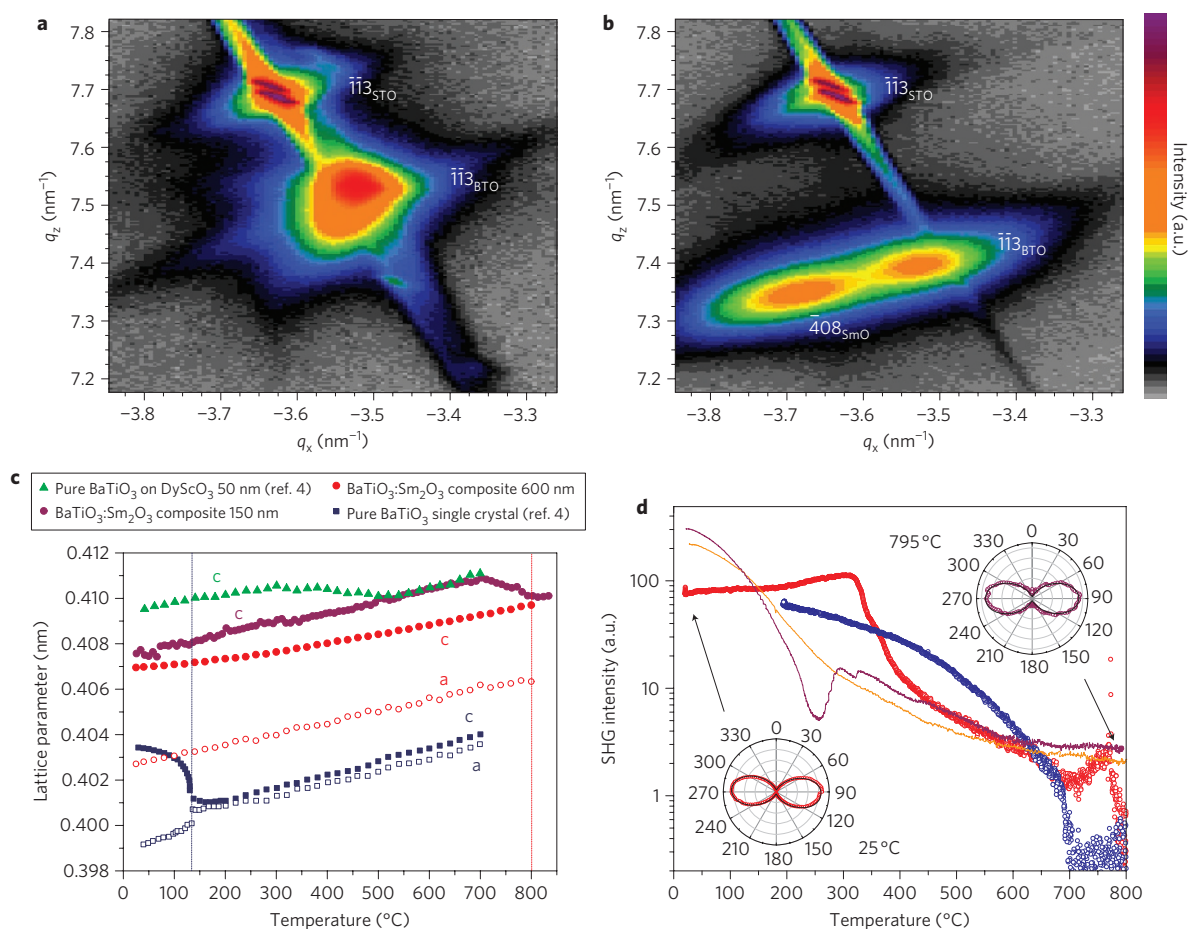


Figure 2 | Enhanced tetragonality at elevated temperature. **a, b**, X-ray reciprocal space maps about the ($\bar{1}\bar{1}3$) of the STO substrate for a pure BTO film (**a**) and a composite film (**b**), both with a thickness of 1 μm. **c**, Temperature dependence of lattice parameters comparing a single crystal and a substrate-controlled pure BTO film (50 nm) (reproduced from ref. 4) with BTO:SmO composite films (150 and 600 nm). Closed symbols: out-of plane lattice parameter calculated from the (002) X-ray peak; open symbols: in-plane lattice parameter calculated from the (101) X-ray peak. **d**, Dependence of SHG signal on temperature for a 600 nm film (purple, heating; orange, cooling) and a 1.25 μm film (red, heating; blue, cooling). Inset: SHG signal (radial distance) versus fundamental polarization (azimuthal angle) at room temperature (25 °C) and 795 °C for *p* (signal polarized in the incidence plane). Black lines are a fit from equation (1) (see Methods).

separate things, detected by different experiments²⁴, so direct electrical measurements were also necessary.

The dielectric constant as a function of frequency and temperature was measured for both pure and composite films (shown at 10, 25, 50 and 100 kHz in Fig. 3, upper inset), and in several composite samples a sharp dielectric peak was measured between ~700 °C and ~800 °C, without a clear dependence of peak temperature on thickness, but broadly consistent with the range of structural transition temperatures measured by X-ray. We observe a peak at 700 °C for a 1-μm-thick film; there was no shift in this peak position with frequency, indicating a normal, rather than diffuse, phase transition²⁵. The peak dielectric constant value was ~7,000. The sharpness of the peak, its frequency invariance and its temperature coincident to the X-ray transition together indicate that a transition from tetragonal to cubic structures is being measured. The pure 1-μm-thick reference film shows a broad peak at over 100 °C and a peak value of ~2,000. The data are typical for a thick pure BTO film^{26–29} where there is a partial relaxation of lattice parameters, as was seen in the reciprocal space map of the reference film (Fig. 2a).

From ferroelectric hysteresis measurements, a 1 μm composite film was confirmed to be ferroelectric to at least 330 °C (Fig. 3). A non-decreasing remanent polarization (P_r) of 21 μC cm⁻² (calculated using the area of the BTO component of the film) was recorded both at room temperature and at 330 °C. The value is similar to that

from our pure BTO films, and those from the literature³⁰, measured at room temperature. The non-square hysteresis behaviour and high coercive field ($E_c \approx 200$ kV cm⁻¹) compared to bulk material ($E_c \approx 1$ kV cm⁻¹; ref. 31) can be explained by the pinning of the ferroelectric/ferroelastic domain walls by the SmO phase. The shift of the loops to the left is caused by the use of different top and bottom electrodes, and the increased area of loop with increasing temperature arises from increased leakage. Because strong polarization is achieved in the BTO matrix with dimensions of only 10 nm, but in free-standing nanowires of similar diameter it is degraded³², it is clear that strain coupling to SmO prevents the BTO from undergoing deleterious surface reconstruction and allows for a stable nanoscale ferroelectric.

The leakage current was reduced (Fig. 3, lower inset) to 2.2×10^{-7} A cm⁻² from 3.3×10^{-6} A cm⁻² (at 200 kV cm⁻¹) for an equivalent pure BTO film. This is consistent with the observations of higher crystalline quality and higher Curie temperature of the BTO in the composite. Both the asymmetry and magnitude of the leakage data are in agreement with the literature³⁰.

In summary, self-assembled nanoscale composites of BTO and SmO (up to 1.25 μm thick) were grown that exhibited tetragonality up to at least 800 °C (potential for ferroelectricity up to this temperature) and strong remanent polarization to at least 330 °C. The enhanced T_c is a consequence of uniform, vertical

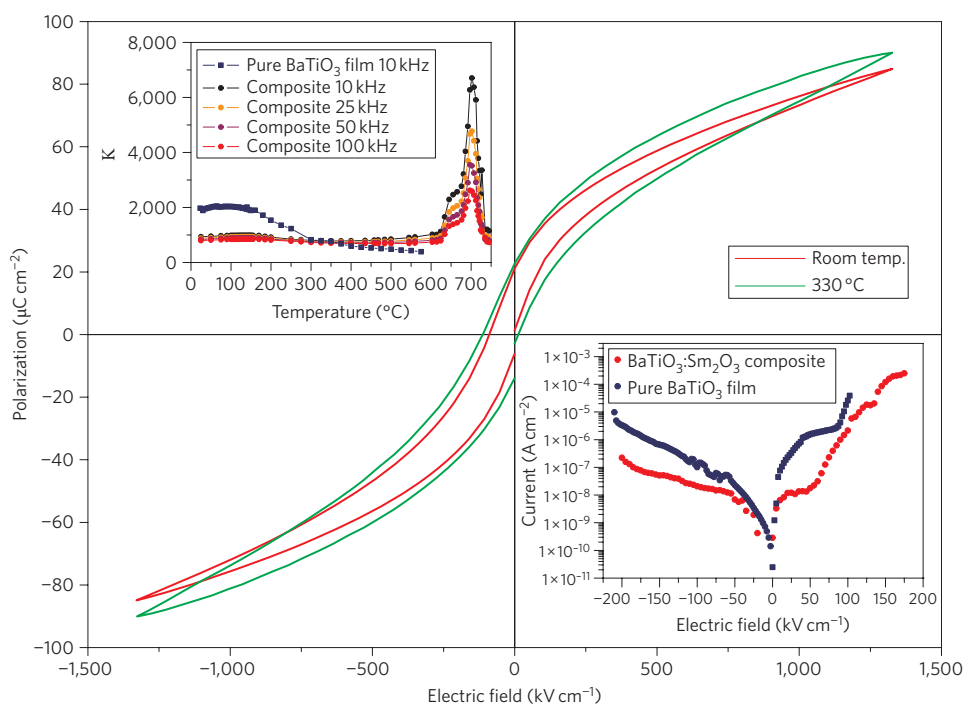


Figure 3 | Direct electrical measurements. Polarization versus electric field hysteresis loops of 1 μm BTO:SmO thin-film capacitors at room temperature and 330 $^{\circ}\text{C}$. Upper inset: dependence of dielectric constant on temperature for pure and composite films with a thickness of 1 μm , at 10, 25, 50 and 100 kHz. Lower inset: leakage current as a function of applied field for the same thickness (600 nm) of pure BTO and BTO:SmO thin films. The Pt top electrode was positively biased.

strain coupling between stiff 10 nm regular interspersed nanocolumns of SmO and a surrounding BTO nanomatrix, preventing the onset of the tetragonal to cubic phase transition. The nanocomposite structure improved BTO crystalline quality and reduced the leakage current.

Methods

Pure BTO and BTO:SmO 50:50 composite films were grown onto (001) 1.4 at% Nb-doped SrTiO₃ substrates at 800 $^{\circ}\text{C}$ in 0.2 mbar of oxygen, by pulsed laser deposition using a KrF laser ($\lambda = 248$ nm) with a fluence of 2 J cm⁻² and a repetition rate of 1 Hz. Film thicknesses in the range 50 nm to 1.25 μm were deposited. TEM was performed on a JEOL 2011FEG/JEOL 4000EX/Philips CM30 microscope. X-ray diffraction was carried out with a Bruker D8 diffractometer using CuK α radiation. Reciprocal space maps were collected about the (103) and (113) of STO and precise peak positions were obtained from asymmetric line scans made across the regions of interest, in combination with profile fitting. Diffraction patterns were obtained *in situ* at high temperature by rapid scans over the (002) (*a* lattice parameter) and skew symmetric scans for the (101) peak (*c* lattice parameters) such that the sample was held at each temperature for no more than 5 min, with temperature steps varying between 5 and 20 $^{\circ}\text{C}$. SHG measurements were carried out at a laser wavelength of 800 nm, with 65 fs laser pulses incident on the substrate side of the sample at an angle of 45 $^{\circ}$. The expected intensities of the SHG signal polarized in the incidence plane (*p*) and perpendicular to the incidence plane (*s*) are given by

$$I_p^{\omega} = A(B \cos^2 \theta + \sin^2 \theta)^2 \quad (1)$$

$$I_s^{\omega} = C \sin^2 2\theta \quad (2)$$

where θ is the angle of the input polarization measured from the plane of incidence, and *A*, *B* and *C* are coefficients that depend on the nonlinear optical coefficients of BTO, indices of refraction and angle of incidence. Pt electrodes ($\sim 3 \times 10^{-8}$ m²) were sputtered onto the film surface, and electrical measurements were carried out using a Radiant 100 precision ferroelectric tester and HP4942A impedance analyser. The dielectric constant was measured with frequency, and its dependence on temperature extracted at 10, 25 and 50 kHz with a 50 mV field. Hysteresis loops were recorded at 1 kHz.

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Author contributions

H.W. and Z.B. collected and analysed TEM images. V.G. and S.D. were responsible for SHG data. C.B.E., S.A.T.R., S.H.B. and C.W.B. were responsible for high-temperature XRD measurements. J.Z. advised on direct electrical measurements. M.E.V. and Q.J. discussed the results and commented on the manuscript. S.A.H. prepared films, collected room-temperature XRD data, performed direct electrical measurements and analysed data. S.A.H. and J.L.M. co-wrote the manuscript.

Additional information

The authors declare no competing financial interests. Supplementary information accompanies this paper at www.nature.com/naturenanotechnology. Reprints and permission information is available online at <http://www.nature.com/reprints>. Correspondence and requests for materials should be addressed to S.A.H.